# Development of SiC Large Tapered Crystal Growth

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Project ID # APE027

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## Overview Barriers

### Timeline

- Funding start: Dec. 2009
- Project end: Dec. 2013
- Percent complete: 70%

### Budget

- Total project funding
  - DoE: \$1600K
  - NASA: \$700K (\$500K FY12)
- \$700K from DOE in FY11
- \$200K from DOE in FY12

# Advanced Power Electronics and Electric Machines (APEEM)

SiC <u>expense</u> and <u>material quality</u> inhibiting higher density and higher efficiency EV power electronics.

Table 1. Technical Targets for Electric Traction System

|                       | 2020 <sup>b</sup> |
|-----------------------|-------------------|
| Cost, \$/kW           | <8                |
| Specific power, kW/kg | >1.4              |
| Power density, kW/L   | >4.0              |
| Efficiency            | >94%              |

### Partners

- NASA Glenn (Lead)
- Ohio Aerospace Institute
- Sest, Inc.
- NASA Postdoctoral Program (Oak Ridge Assoc. Universities) 2

## Objectives

- SiC power semiconductor devices <u>should theoretically</u> enable vastly improved power conversion electronics compared to today's silicon-based electronics.
  - •2-4X converter size reduction and/or 2X conversion loss reduction (theoretical performance gains vary with system design specifications).
  - Fundamentally improved implementation of smart grid, renewable energy, electric vehicles, aircraft and space power systems.
- SiC <u>wafer defects</u> and <u>cost</u> inherent to existing SiC material growth approach presently inhibiting larger benefits from becoming more widely available.
- New but unproven NASA "Large Tapered Crystal" (LTC) SiC growth concept proposed to lower SiC material defect and cost technology barrier.

| U.S. DEPARTMENT OF | Energy Efficiency &<br>Renewable Energy | Vehicle Technologies Program Multi-Year Program | Plan (2011-2015) |
|--------------------|---|---|------------------|
|--------------------|---|---|------------------|

|        | Table 2.1-6 Tasks for Advanced Power Electronics and Electric Motors R&D   |                       |  |  |
|--------|--|-----------------------|--|--|
| Task   | Title  | Barriers<br>Addressed |  |  |
| Task 1 | <ul> <li>Power Electronics Research and Development New Topologies- achieve significant reductions in PE weight, volume, and cost, and improve performance: <ul> <li>Reduce need for capacitance by 50%–90%, to yield 20% – 35% inverter volume reduction and cost reduction</li> <li>Reduce part count by integrating functionality, to reduce inverter size and cost, and increase reliability</li> <li>Reduce inductance, minimize electromagnetic interference and ripple, and reduce current through switches, all resulting in reduced cost</li> </ul> WBG semiconductors - higher reliability and higher efficiency, and enable high- temperature operation</li></ul> | A, B, C, D, E, F      |  |  |

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## **Objectives**

#### **Overall Objectives (Longer Term)**

- Open a new technology path to large-diameter SiC and GaN wafers with 100-1000 fold total crystal defect (dislocation) density improvement at 2-4 fold lower cost. (Present SiC wafers ~ 10<sup>3</sup>-10<sup>4</sup> total dislocations per cm<sup>2</sup>.)
- Enable leapfrog improvement in wide bandgap power device capability and cost to in turn enable leapfrog improvements in electric power system performance (higher efficiency, smaller system size).

#### **Funded Project Objective (Shorter Term)**

- Demonstrate <u>initial feasibility</u> of radically new "Large Tapered Crystal" (LTC) approach for growing vastly improved large-diameter SiC semiconductor wafers.
- Verify needed (never experimentally demonstrated) LTC growth physics in laboratory setting:
  - Growth of long, small-diameter single-crystal 4H-SiC fibers.
  - Lateral "M-plane" enlargement of 4H-SiC fibers into boules.



First SiC experimental demonstrations of the two critical growth actions required for Large Tapered Crystal (LTC) process.

| Month/Year    | Milestone   |
|---------------|---|
| May 2011      | Demonstrate epitaxial radial (lateral) growth of a 5 mm diameter boule starting from a simulated SiC fiber crystal. |
| December 2011 | Demonstrate laser-assisted fiber growth of a SiC fiber crystal greater than 10 cm in length.                        |

LTC is **NOT** viable without success of BOTH processes.

As discussed in this presentation, neither above <u>quantitative milestone</u> <u>challenges</u> have been met within the original project schedule.

# Approach/Strategy

#### Present SiC Growth Process

(Vapor transport)



Vertical (c-axis) growth proceeds from top surface of large-area seed via thousands of dislocations. (i.e., dislocation-mediated growth!)

Crystal grown at T > 2200 °C High thermal gradient & stress.

Limited crystal thickness.

#### Proposed LTC Growth Process

(US Patent 7,449,065 OAI, Sest, NASA)

Vertical Growth Process: Elongate small-diameter fiber seed grown from single SiC dislocation.

#### Lateral Growth Process:

CVD grow to enlarge fiber sidewalls into large boule. - 1600 °C, lower stress

- Only 1 dislocation

Lateral & vertical growth are simultaneous & continuous (creates tapered shape).

Radically change the SiC growth process geometry to enable full SiC benefit to power systems.

#### **Approach/Strategy** (Solvent-LHFZ)- A New and Unique SiC fiber Growth Method



(Non-Crystalline Source Material)

- 88 Experimental Solvent-LHFZ runs since 2011 Review.
- 10 Changes to feed rod processing technique, 5 feed rod material compositions tested, 5 seed crystal configurations tested.
- Have achieved single crystal growth rates >100  $\mu m$ /hour (polycrystalline > 400  $\mu m$ /hour)
- Demonstrated control over growth rates.

| Experimental Condit<br>(M.P. = Feed Rod Melt |          |           | Growth Rate | es (μm/hour)   |             |
|--|----------|-----------|-------------|----------------|-------------|
| Fe/Si  | C (at.%) | M.P. (°C) | M.P.+90 °C  | M.P.+190<br>°C | M.P.+325 °C |
| Fe/Si~0.35                                   | 8        | 1170      | 4           | 40             | 135+        |
|  | 16       | 1195      | 50          | 120            | N/A         |
| Fe/Si~1.9                                    | 8        | N/A       | No growth   |                |             |

\* Temperatures not corrected for emissivity.

Woodworth et al., ICSCRM 2011

#### Solvent-LHPG SiC Fiber Growth

- Layer polytype confirmed via X-ray topography (Prof. Dudley @ SUNY)
- Non-ideal "cut seed" crystal growth front is large (~ 0.5 mm<sup>2</sup>).
  - Many screw dislocations many growth centers (not wanted for LTC).
  - Chaotic growth front merphology is observed (likely creates defects).



#### Radial/Lateral CVD Epi-Growth

4H/6H SiC a/m-plane slivers prior to growth

[0001][0001] c-axis Basal plane  $(1\overline{1}00)$ (1120)m-plané a-plane pseudo fiber [1120] [1100] m-plane a-plane

Slivers after 8 hours of CVD epitaxial growth



- Post-growth crystals are translucent and exhibit lateral expansion (a/mface growth).
- 3C-SiC crystallites (yellow) undesirably nucleated in some areas.

Synchrotron white beam X-ray topograph (top) and diffraction pattern (bottom) of sliver after 8 hours of growth (from Prof. Dudley's group at Stony Brook U.)



Confirmation of <u>hexagonal polytype replication and low strain</u> during CVD growth (for "clean" regions where parasitic 3C-SiC nucleation did not occur).

#### Radial/Lateral CVD Epi-Growth

#### NASA Glenn SiC CVD Growth System Major Equipment Failure (RF Generator) on August 12, 2011



- <u>Heavily damaged</u> sub-system returned to manufacturer for replacement/repair.
- New RF generator procured (using \$100K of NASA funds).
- All lateral CVD SiC epitaxial growth work suspended for > 5 months.
- Delayed new/improved seeding of Solvent-LHFZ growths.
- Operations resumed using repaired sub-system on January 23, 2012.
- 22 operational runs conducted in 36 working days following repairs.

Radial/Lateral CVD Epi-Growth



Epi Growth Rate: ~80 µm/hour Max. Film Thickness: ~0.15 mm Max Diameter: ~1 mm (mostly seed) Rough grown surfaces/mini-facets Epi Growth Rate: ~ 120 µm/hour Max. Film Thickness: ~2 mm Max Diameter: ~4 mm (mostly epi) (80% of 5 mm Quantitative Milestone) Smooth Tapered Hexagonal Facets!

## Proposed Future Work

Radial/Lateral CVD Epi-Growth



Carry out detailed characterization of larger mini-boules.

- Including X-ray Topography by Prof. Dudley's group at SUNY.
- Answer critical question: Are stacking faults produced during thick radial CVD?

CVD growth hardware & crystal mounting modifications to suppress 3C-SiC.

Grow and characterize increasingly larger mini-boules.

### Proposed Future Work Fiber Growth

Smaller, well-ordered seed with pointed tip is needed for fiber growth.



P. Neudeck, 2009 DRIP Conf.

Transition to micro-patterned "single screw hexacone" (produced by patterned etching followed by CVD epi as described in LTC patent).

Further refinement of seed rods (materials, smaller diameter) and solvent-LHPG growth process.

In addition to solvent-LHPG growth, LTC patent also describes laser-assisted vapor-growth methods for growing long single-crystal fiber (from same "hexacone" SiC seeds).

Free Form Fibers LLC (NY) – Initiating SBIR Phase III (NASA Funded \$100K) for laser-assisted <u>SiC fiber growth using gas precursors</u>.

- Small business presently laser-growing **polycrystalline** SiC fiber shapes.
- Parallel path (risk mitigation) to realize **single-crystal** SiC fiber growth if technical challenges of Solvent-LHFZ approach cannot be overcome.

### Collaboration and Coordination with Other Institutions

- NASA Glenn Research Center (Prime)
  - SiC crystal growth and ceramic fiber growth research branches
    - Ohio Aerospace Institute (Non-Profit)
    - Sest, Inc. SiC Crystal Characterization
    - NASA Postdoctoral Program (Oak Ridge Assoc. Universities)
- State University of New York at Stony Brook National Synchrotron Light Source at Brookhaven National Laboratory (Dept. of Energy)
  - Prof. Dudley's group recognized leader in X-Ray topographic mapping characterization of SiC crystals and defect structure.
- Free Form Fibers LLC (NY) Initiating SBIR Phase III (NASA Funded \$100K) for laser-assisted <u>SiC fiber growth using gas precursors</u>.
  - Small business laser-growing **polycrystalline** SiC fiber shapes.
  - Parallel path (risk mitigation) to realize single-crystal SiC fiber growth if technical challenges of Solvent-LHFZ approach cannot be overcome.

# Summary

 Experiments to investigate feasibility of revolutionary new "Large Tapered Crystal (LTC)" SiC growth approach are behind schedule, but significantly progressing towards demonstration goals.

| Technical<br>Area  | 2011 Status   | 2012 Status   |  |
|--|---|---|--|
| Radial Growth  | System build-up complete<br>First layers documented<br>~ 1 mm diameter<br>~80 µm/hour growth rate | First "Mini-boules" grown<br>~ 4 mm diameter<br>~125 µm/hour growth rate<br>Desired hex facet evolution |  |
| Fiber GrowthSystem build-up complete<br>First Solvent-LHFZ layersSolvent-LHFZ > 100 µm/hour<br>Laser-CVD Effort InitiatingDevelopmental acceleration expected with addition of<br>NASA resources, expanded LTC development team. |   |   |  |

## **Technical Acknowledgements**

NASA LTC Co-Investigators:

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# **Technical Back-Up Slides**

(Note: please include this "separator" slide if you are including back-up technical slides (maximum of five). These back-up technical slides will be available for your presentation and will be included in the DVD and Web PDF files released to the public.)

## **Unipolar Power Device Comparison**

(Volume Production Commercial Devices)

SiC devices are ~2X voltage or current-density **de-rated** from theoretical material performance.



Above comparison does NOT take yield, cost, other relevant metrics into account.

## SiC Wafer Material Defects

Over the past decade there have been numerous studies (including NASA GRC) linking <u>degraded</u> SiC power device performance, yield, and reliability to the presence of defects in the SiC wafer crystal.

Magnified view <u>small area in middle of wafer</u> imaged by Ultra-Violet Photoluminescence

- Each white dot or line is a dislocation defect!
- Average dislocation density  ${\sim}10^4~\text{per}~\text{cm}^2$





## Production LTC SiC Growth System

Simplified Schematic Cross-Sectional Representation



Features (one embodiment):

- 1. 3-Region growth apparatus for 3 different growth actions.
- 2. Region 1: Vertical (c-axis) growth on a <u>very small diameter</u> columnar portion ("Fiber Growth").
- 3. Region 2: Lateral (m-direction) growth on fiber & tapered portion ("Lateral Growth").
- 4. Region 3: No growth after LTC boule reaches desired diameter.
- 5. Growth rate of boule in caxis direction equals fast growth rate of columnar seed crystal.
- 6. Boule contains only one dislocation along its axis; the remainder of the boule is nominally defect-free.

Previously reported build-up and safety reviews of laser-assisted fiber growth and radial epitaxial growth hardware <u>are now complete.</u>





(Photos previously presented at FY11 VTP Kickoff Meeting)

Both systems are now operational and growing experimental SiC crystals!

## Prior a-face/m-face SiC Growth Research

Takahashi & Ohtani, Phys. Stat. Solidi B, vol. 202, p. 163 (1997).





Defects were found to increase as a-face growth proceeded.

Attributed to low energy difference between stacking configurations on the growth surface.

BUT – This prior work was physical vapor transport (PVT) growth at T > 2000 °C, high thermal gradient.

Key LTC feasibility question – will stacking faults form in CVD, isothermal, T ~1600 °C?

